

FEOC Compliance Certificate

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Issued: 2026-06-09

Verification ID: FEOC-2DD9E5C2ECEC

Source: live federal-list snapshot

Naura Technology Group Co., Ltd.

China · COVERED NATION · Entity · ID: NK-VtCxR7S6MUN7LDFTP6yfh9::BIS_ENTITY_LIST

FEOC FLAGGED

Why this matters: Naura Technology Group Co., Ltd. appears on a critical federal screening list. Equipment, services, or transactions involving this entity likely fail FEOC requirements for IRA tax credits (45X, 48E, 30D). Confirm identity against the cited authority before procurement or compliance decisions.

FEDERAL-LIST SCREENING MATRIX

LIST	AUTHORITY	STATUS	LISTED AS	SEVERITY
OFAC SDN	Treasury OFAC	Not listed	—	CRITICAL
BIS Entity List	Commerce / BIS	Listed	Naura Technology Group Co., Ltd.	CRITICAL
DOD 1260H (Chinese Military Companies)	DOD	Not listed	—	CRITICAL
UFLPA Entity List	DHS / FLETF	Listed	Sichuan Jingweida Technology Group Co. Ltd.	CRITICAL
CBP Withhold Release Orders	DHS / CBP	Not listed	—	CRITICAL
BIS Denied Persons	Commerce / BIS	Not listed	—	HIGH
BIS Military End User	Commerce / BIS	Not listed	—	HIGH
BIS Unverified List	Commerce / BIS	Not listed	—	MEDIUM
State ITAR Debarred	State Department	Not listed	—	HIGH
State Nonproliferation	State Department	Not listed	—	HIGH

ALSO KNOWN AS

Beifang Huachuang · Naura · Naura Science & Technology Group · Northern Huachuang

KNOWN ADDRESSES

• No. 1 Jiuxianqiao East Road, Chaoyang District, Beijing

SANCTIONS PROGRAMS / AUTHORITIES

US-BIS-EL

SANCTIONING AUTHORITY NOTES

DATA SOURCES

BIS Entity List <https://www.bis.gov/entity-list>
UFLPA Entity List <https://www.dhs.gov/uflpa-entity-list>

Informational only. Not legal advice. Cross-list matching is name-based — verify identity with the cited source authority before procurement, financing, or compliance decisions.

This document is a point-in-time snapshot. The Verification ID can be reproduced from the entity ID + the date of issue.

Verification ID: FE0C-2DD9E5C2ECEC · Entity ID: 26db5b87-ef55-46ab-8aa0-56e3c16c55d2 · Issued 2026-06-09